

UE Advanced semiconductor devices





Component
UFR PhITEM
(physique,
ingénierie, terre,
environnement,
mécanique)



Semester Automne

> Teaching language(s): English

Open to exchange students: Yes

Code d'export Apogée: PAX9NPAK

Presentation

Description

The first part will give an overview of semiconductor devices trends and evolutions for calculations. Limits of traditional architectures as transistors and memories will be studied. Then we will described emerging solutions for calculations and memories including devices and architectures for advanced computing and artificial intelligence. The second part will address the physics of light emitting diodes.

Part I Semiconductor devices trends and evolutions for calculation

I.1 Moore's law limits and solutions

MOSFET nano-transistors basics

Static and dynamic power

New architectures (Finfet, Nanowires)

Dynamic power regulation

Variability at ultimate scaling

I.2 Memories

Volatile memories

DRAM

SRAM

Non-volatile memories : Flash memories

I.3 Emerging non-volatile memories

Resistive random access memories (OxRAM, CBRAM, PCRAM)





Crossbar and 3D architectures

Magnetic random access memories and spintronics

I.4 3D Technologies for heterogeneous integration

2D integration limitations

Parallel 3D

Sequential 3D

Applications to advanced calculations, smart imagers, photonics.

I.5 From CMOS to single electron devices

New phenomena at ultimate scaling

Low temperature electronics

Single electron transistor

Toward (single) spin electronics and quantum calculations

I.6 Emerging computing paradigms for AI

Some basics of neuromorphic computing

Convolutional neuronal networks

Spiking neurones using resistive memories

Fading the limits been memory and calculation.

Part II Light emitting diodes: Physics and devices

- II.1 Fundamentals of radiative recombination in semiconductors.
- II.2 Homojunction vs heterojunction Light emitting diodes.
- II.3 Light emitting diode materials: growth and fabrication techniques.
- II.4 Light emitting diode efficiency (injection, extraction).
- II.5 Specificity of III-nitride Light emitting diodes (e.g. internal electric field, disorder).

Course parts

UE Advanced semiconductor devices - CMTD

Lectures (CM) & Teaching Unit (UE)

18h

UE Advanced semiconductor devices - TP

Practical work (TP)

8h

Recommended prerequisites

For part I: from M1: Basic principles (documents can be provided)

Diode, MOS Capacitance, MOSFET, Electronic transport in a semiconductor and in and oxide.

for part II: p-n junction, electronic structures, quantum wells.

Period: Semester 9

Useful info





Campus

> Grenoble - University campus

